



11 - JFET MESFET HEMT

Name: _____ Complete _____

Agenda: (1) review the quiz / (2) 5 minutes minimum for lecture questions and review / (3) start the problems!

In-Class Problems

(1) Let's design a JFET. An ideal Si p+n junction at 300K has the following parameters (you may or may not need them all).

<u>p-side:</u>	<u>n-side:</u>	<u>General parameters</u>
$N_a=10^{17}/\text{cm}^3$	$N_d=10^{15}/\text{cm}^3$	$A=10^{-6} \text{ cm}^2$
$D_n=18 \text{ cm}^2/\text{sec}$	$D_p=25 \text{ cm}^2/\text{sec}$	$\epsilon_{\text{Si}}=11.8$
$L_n=10^{-3} \text{ cm}$	$L_p=10^{-2} \text{ cm}$	
$\mu_p=200 \text{ cm}^2/\text{V-s}$	$\mu_n=1300 \text{ cm}^2/\text{V-s}$	
$\mu_n=700 \text{ cm}^2/\text{V-s}$	$\mu_p=450 \text{ cm}^2/\text{V-s}$	

$$V_o=0.0259*\ln(10^{32}/2.25*10^{20})=0.695\text{V}$$

a) Calculate the drift current across the junction at no applied bias (0V). This will be the amount of JFET gate current you need. Is it small or large?

b) Calculate the width of the depletion region (W) at no applied bias (0V).

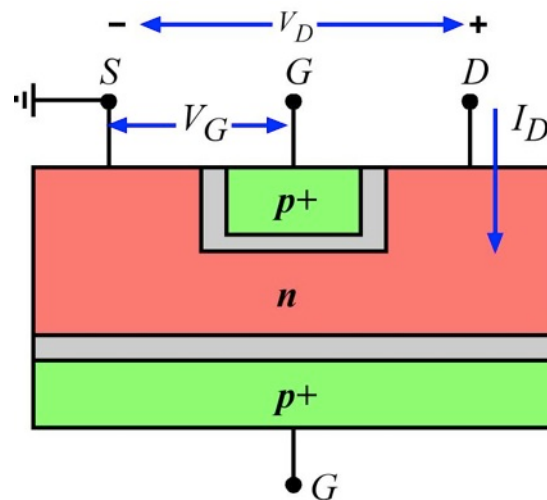
c) You use the above materials to make a JFET. If you want a conducting portion of the channel that is at least 3 μm thick, what is the distance you will need between the semiconductor regions making up the gate?

d) How much gate voltage then will it require to turn this JFET fully OFF?

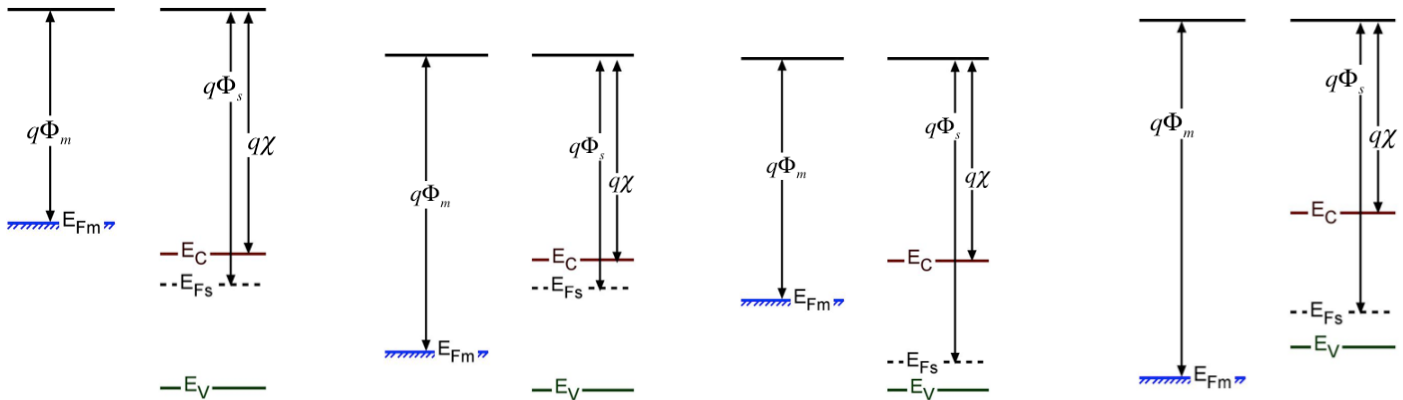
e) Lastly, calculate the maximum output current for the case where the source is grounded (0V). Assume that the length of the channel (L) is 3.16 μm and the depth (Z) of the channel is 31.6 μm (ends up being like the area we listed above at $1\text{E-}6 \text{ cm}^2$, $Z/L = 10$). You will need 'a' too, but that is easy as you can get it from part (c).

Since you know what was the source voltage is, then you should be able to easily see what you should have for V_g , and then plug away at the equation below. Compare this to the amount of current required to reverse bias the gates and comment.

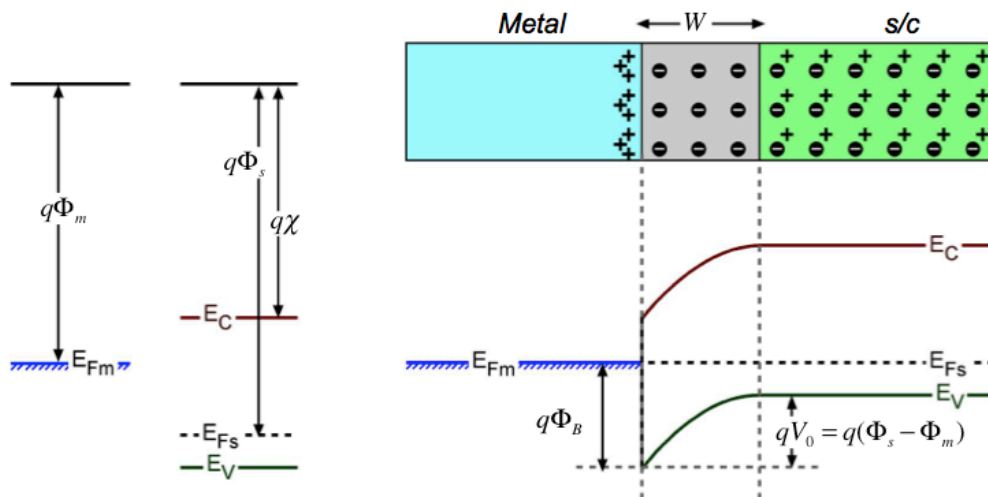
$$I_D(\text{sat.}) = G_0 V_p \left[\frac{V_G}{V_p} - \frac{2}{3} \left(\frac{V_G}{V_p} \right)^{3/2} + \frac{1}{3} \right] \quad V_p = \frac{q a^2 N_D}{2\epsilon} \quad G_0 = \frac{2aZ}{\rho L} \quad \sigma = q\mu_n n_0 = \rho^{-1}$$



(2) Which of the following metal-semiconductor contacts can be used to construct a MESFET gate? Just quickly and roughly sketch the band diagrams to see if they are ohmic or rectifying.



(3) Now lets review the basics for a MESFET, which is a transistor where the input is a Schottky diode capacitor... Consider a metal-semiconductor (Schottky) diode with a p-type semiconductor.



(a) How would you calculate reverse bias capacitance for a metal-semiconductor (Schottky) diode with a p-type semiconductor? Give the revised formula as a function of the contact potential for the metal-semiconductor diode. For once, lets have YOU derive the formula on your own from something we already know...

$$W = \sqrt{\frac{2\epsilon kT}{q^2} \left(\ln \frac{N_A N_D}{n_i^2} \right) \left(\frac{1}{N_A} + \frac{1}{N_D} \right)}$$

Hint: above is depletion width for a PN junction. This is easy:

- (1) replace the part of W above that is contact potential, with just V_0
- (2) then simplify further considering the metal is like n+++ and the p is therefore the lightly doped side
- (3) the use the simple parallell plate capacitor formula to get capacitance!

(b) Well, once you have this formula from (a), you could calculate the capacitance per unit area, if you just knew the contact potential and the doping level... so lets do it!

The electron affinity for most semiconductors like Ge, Si, and GaAs is ~ 4.0 eV. Assume W metal with a workfunction of 4.6 eV is deposited onto Si doped to 10^{18} with Boron. Calculate the contact potential. Hint: Remember, this doping shifts

the Fermi level down (and therefore the semiconductor workfunction), by $kT \times \ln(N_A/n_i)$. So 1st, calculate the semiconductor workfunction. Just looking at the diagram, the work function (Φ) should be the electron affinity (χ), plus $\frac{1}{2}$ the bandgap, plus the amount the Fermi level shifted down from the undoped Fermi level.

(c) Last question, one thing we like about MESFETs is we can make small gates and therefore also small (short) channel lengths, for a given MESFET, if we decrease the gate by a factor of 5, how much will the RC time constant be reduced for each one of a bunch of MESFETs connected in a circuit? This shows you one reason why we like to make SMALLER transistors!

Hint, like in lecture, feed one MESFET into another, and the capacitance is due to the gates (the gate area) and the resistance is the previous MESFETs channel resistance (length).

Further Problems (if you have time, finish during class when I can help, or on your own time)

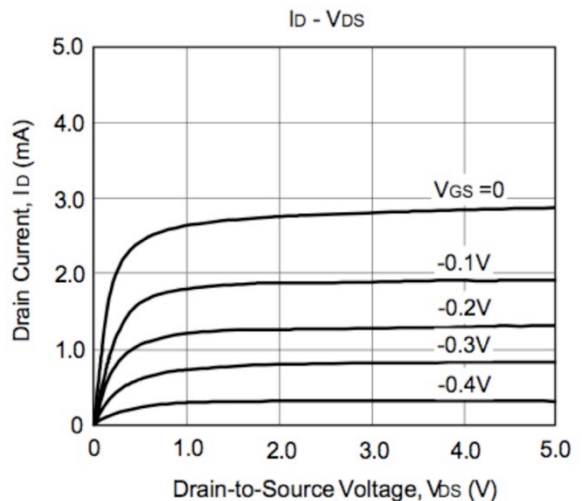
(4) This question is related to heterojunctions. The goal is to convince you that you know enough to create the band diagram for ANY set of semiconductors and metals. These are GaN semiconductors where the column III element (Ga) is partially replaced with other column III elements (such as In, and Al) to change the bandgap.

GaN has a bandgap of 3.4. GaAlN has a bandgap of 3.8 (only a little bit of Al added). GaInN has a bandgap of 3.1 (only a little bit of In added). You may assume that the Fermi levels for intrinsic versions of these materials would be equal.

Draw a band-diagram for a metal / n GaN / p+ GaInN / n GaAlN. Assume the metal workfunction is the same as the electron affinity for the GaN (which is the vacuum level to conduction band). The diagram need not be exact, but should be representative.

(5) Consider the transistor characteristics shown at right for commercial JFET

- a) The current saturates as V_{ds} increases because:
 - the source-drain resistance kicks in.
 - the gate/drain pn junction grows and depletes the channel.
 - the gate/drain pn junction becomes forward biased.
- b) The conducting channel for the source and drain is:
 - p-type.
 - n-type.
 - you can't tell, it could be either.



c) If we place this JFET in a circuit that has a 2 V drain voltage and an output resistance (JFET + external wires) of 0.5 k Ω , from your best estimate, what would be the value for I_D if $V_{GS} = -0.25$ V? Hint, draw a line on the plot above...

d) Calculate the transconductance at saturation.

